Art Unit: ***

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09/29/03

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Claims 1-13 are canceled.

- 14. (New) A resin-encapsulated semiconductor apparatus comprising:
- a semiconductor device having a ferroelectric film and a surface-protective film, and

an encapsulant member comprising a resin;
wherein said surface-protective film consists of a heat-cured
polyimide prepared by heat-curing a polyimide precursor
containing:

a polyimide acid comprising repeating units represented by a chemical formula (I) as given below;

an amine compound having carbon-carbon double bonds;

a photopolymerization initiator and/or a sensitizer wherein

an amount of said amine compound is 1 to 400 parts by weight based on 100 parts by weight of said polyimide precursor and a total amount of said photopolymerization initiator and said sensitizer is 0.1 to 30 parts by weight based on 100 parts by weight of said polyimide precursor;

Art Unit: ***

Formula (I)

$$\left\{
\begin{array}{c}
-CO-R^1-CO-NH-R^2-NH\\
(COOH)_2
\end{array}
\right\}$$
... (1)

wherein R^1 is at least one of tetravalent aromatic organic groups shown in the following chemical formula group (II) shown below, and R^2 is at least one of divalent aromatic organic groups shown in a chemical formula groups (III) and (IV) shown below;

Formula (II)

...(11)

Formula (III)

Art Unit: ***

Formula (IV)

Formula (IV)

Application/Control Number: 10/671,681
Art Unit: ***

- apparatus according to claim 14, wherein said heat-cured polyimide has a glass transition temperature of from 240°C to 400°C.
- 16. (New) The resin-encapsulated semiconductor apparatus according to claim 14, wherein said heat-cured polyimide has a Young's modulus of from 2600 MPa to 6 GPa.
- 17. (New) The resin-encapsulated semiconductor apparatus according to claim 15, wherein said heat-cured polyimide has a Young's modulus of from 2600 MPa to 6 GPa.
- 18. (New) A process for manufacturing a resinencapsulated semiconductor apparatus comprising a
 semiconductor device having a ferroelectric film and a
 surface-protective film, and an encapsulant member comprising
 a resin, comprising steps of:

forming said surface-protective film consisting of a heat-cured polyimide by heat-curing a polyimide precursor containing:

a polyimide acid comprising repeating units represented by a chemical formula (I) as given below;

Art Unit: ***

an amine compound having carbon-carbon double bonds;

a photopolymerization initiator and/or a sensitizer wherein

an amount of said amine compound is 1 to 400 parts by weight based on 100 parts by weight of said polyimide precursor and a total amount of said photopolymerization initiator and said sensitizer is 0.1 to 30 parts by weight based on 100 parts by weight of said polyimide precursor;

Formula (I)

wherein R¹ is at least one of tetravalent aromatic organic groups shown in the following chemical formula group (II) shown below, and R² is at least one of divalent aromatic organic groups shown in a chemical formula groups (III) and (IV) shown below;

Formula (II)

Formula (III)